



"RESPONSE UNDER 37 CFR 1.116-
EXPEDITED PROCEDURE EXAMINING
GROUP 1765"

DOCKET NO: 0039-7632-0X

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

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IN RE APPLICATION OF :
HIROYUKI YANO, ET AL. : EXAMINER: DEO, DUY VU NGUYEN
SERIAL NO: 09/531,163 :
FILED: MARCH 17, 2000 : GROUP ART UNIT: 1765
FOR: AQUEOUS DISPERSION, :
AQUEOUS DISPERSION FOR
CHEMICAL MECHANICAL POLISHING
USED FOR MANUFACTURE OF
SEMICONDUCTOR DEVICES, METHOD
FOR MANUFACTURE OF
SEMICONDUCTOR DEVICES, AND
METHOD FOR FORMATION OF
EMBEDDED WIRING

AMENDMENT AND REQUEST FOR RECONSIDERATION

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Responsive to the Office Action of October 2, 2003, Applicants respectfully request reconsideration of the above-identified application in view of the following amendment and remarks.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Basis for the Amendment begins on page 7 of this paper and includes an attached replacement sheet.

Request for Reconsideration begins on page 8 of this paper.